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(54) **THERMOFORMABLE POLYMER THICK FILM TRANSPARENT CONDUCTOR AND ITS USE IN CAPACITIVE SWITCH CIRCUITS**

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(58) **Field of Classification Search**

None

See application file for complete search history.

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(56) **References Cited**

U.S. PATENT DOCUMENTS

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2003/0151028	A1	8/2003	Lawrence et al.
2004/0173781	A1	9/2004	Lawrence et al.
2005/0236603	A1	10/2005	Faris
2009/0169724	A1	7/2009	Ogiwara
2013/0068512	A1	3/2013	Dorfman et al.
2014/0037941	A1	2/2014	Dorfman et al.

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OTHER PUBLICATIONS

(PCT/US2015/020918) International Search Report and Written Opinion mailed Jun. 10, 2015.

(PCT/US2015/020937) International Search Report and Written Opinion mailed Jun. 11, 2015.

U.S. Appl. No. 14/050,525, filed Oct. 20, 2013, Dorfman et al.

U.S. Appl. No. 14/175,085, filed Feb. 7, 2014, Dorfman et al.

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(57) **ABSTRACT**

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This invention is directed to a polymer thick film transparent conductive composition that may be used in applications where thermoforming of the base substrate occurs, e.g., as in capacitive switches. Polycarbonate substrates are often used as the substrate and the polymer thick film conductive composition may be used without any barrier layer. Depending on the specific design, the thermoformable transparent conductor may be below or on top of a thermoformable silver conductor. Thermoformable electric circuits benefit from the presence of an encapsulant layer over the dried polymer thick film conductive composition. The electrical circuit is subsequently subjected to a injection molding process.

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32 Claims, No Drawings

**THERMOFORMABLE POLYMER THICK
FILM TRANSPARENT CONDUCTOR AND
ITS USE IN CAPACITIVE SWITCH
CIRCUITS**

FIELD OF THE INVENTION

This invention is directed to polymer thick film transparent conductive compositions that may be used in applications where thermoforming of the base substrate occurs. Polycarbonate substrates are often used and the conductor may be used without any barrier layer.

BACKGROUND OF THE INVENTION

Conductive PTF circuits have long been used as electrical elements. Although they have been used for years in these types of applications, the use of PTF silver conductors in thermoforming procedures is not common. This is particularly important in circuits where a highly conductive silver composition is needed after the severe thermoforming process. Additionally, the typical substrate used for thermoforming is polycarbonate and very often the conductor is not compatible with this substrate. One of the purposes of this invention is to alleviate these issues and produce a conductive, thermoformable construction in which a printed transparent conductor can be used either on a substrate of choice such as a polycarbonate or as part of the capacitive circuit stack where it can be printed below or above silver.

SUMMARY OF THE INVENTION

This invention relates to a polymer thick film transparent conductive composition comprising:

- (a) 10-70 wt % of a conductive oxide powder selected from the group consisting of indium tin oxide powder, antimony tin oxide powder and mixtures thereof;
- (b) 10-50 wt % of a first organic medium comprising 10-50 wt % thermoplastic urethane resin dissolved in a first organic solvent; wherein the weight percent of the thermoplastic urethane resin is based on the total weight of the first organic medium; and
- (c) 10-50 wt % of a second organic medium comprising 10-50 wt % thermoplastic polyhydroxyether resin dissolved in a second organic solvent wherein the weight percent of the thermoplastic polyhydroxyether resin is based on the total weight of the second organic medium;

wherein the weight percent of the conductive filler, the first organic medium and the second organic medium are based on the total weight of the polymer thick film conductive composition.

In an embodiment, the polymer thick film transparent conductive composition further comprises:

- (d) 1-20 wt % of a third organic solvent, wherein the third organic solvent is diacetone alcohol and wherein the weight percent is based on the total weight of the polymer thick film conductive composition.

In one embodiment, the conductive oxide powder particles are in the form of flakes.

The invention is further directed to using the thermoformable conductive composition to form conductive electrical circuits for capacitive switches and, in particular, in the thermoforming of the total construction. In one embodiment an encapsulant layer is deposited over the dried PTF transparent conductor composition.

DETAILED DESCRIPTION OF INVENTION

The invention relates to a polymer thick transparent conductive composition for use in thermoforming electrical circuits and, in particular, capacitive switch circuits. A layer of conductor is printed and dried on a substrate so as to produce a functioning circuit and then the entire circuit is subjected to pressure and heat that deforms the circuit to its desired three dimensional characteristics, i.e., thermoforming.

The substrates commonly used in polymer thick film thermoformed circuits are polycarbonate (PC), PVC and others. PC is generally preferred since it can be thermoformed at higher temperatures. However, PC is very sensitive to the solvents used in the layers deposited on it.

The polymer thick film (PTF) conductive composition is comprised of (i) a conductive oxide powder selected from the group consisting of indium tin oxide (ITO) powder, antimony tin oxide (ATO) powder and mixtures thereof, (ii) a first organic medium comprising a first polymer resin dissolved in a first organic solvent and (iii) a second organic medium containing a second polymer resin dissolved in a second organic solvent.

In an embodiment that results in no crazing or deformation of the underlying substrate onto which the PTF transparent conductive composition is printed, the PTF conductive composition further comprises a third solvent, diacetone alcohol.

Additionally, powders and printing aids may be added to improve the composition.

The use of the term transparent is a relative one. Herein, transparent is meant to mean at least 30% light transmission through the printed/dried conductor.

Each constituent of the electrically conductive composition of the present invention is discussed in detail below.

A. Transparent Conductive Powder

The conductors in the present thick film composition are ITO powder, ATO powder, or mixtures thereof. Various particle diameters and shapes of the powder particles are contemplated. In an embodiment, the conductive powder particles may include any shape, including spherical particles, flakes (rods, cones, plates), and mixtures thereof. In one embodiment, the ITO is in the form of flakes.

In an embodiment, the particle size distribution of the ITO and ATO powders is 0.3 to 50 microns; in a further embodiment, 0.5-15 microns.

In an embodiment, the surface area/weight ratio of the conductive oxide powder particles is in the range of 1.0-100 m²/g.

ITO is tin-doped indium oxide, Sn:In₂O₃, i.e., a solid solution of In₂O₃ and SnO₂ with typically 90 wt % In₂O₃ and 10 wt % SnO₂. ATO is antimony-doped tin oxide, Sb:SnO₂, i.e., a solid solution of Sb₂O₃ and SnO₂ with typically 10 wt % Sb₂O₃ and 90 wt % SnO₂.

Furthermore, it is known that small amounts of other metals may be added to transparent conductor compositions to improve the electrical properties of the conductor. Some examples of such metals include: gold, silver, copper, nickel, aluminum, platinum, palladium, molybdenum, tungsten, tantalum, tin, indium, lanthanum, gadolinium, boron, ruthenium, cobalt, titanium, yttrium, europium, gallium, sulfur, zinc, silicon, magnesium, barium, cerium, strontium, lead, antimony, conductive carbon, and combinations thereof and others common in the art of thick film compositions. The additional metal(s) may comprise up to about 1.0 percent by weight of the total composition. However, the degree of transparency may suffer as these metals are added.

In one embodiment, the conductive oxide powder is present at 20 to 70 wt %, based on the total weight of the PTF conductive composition. In another embodiment, it is present at 30 to 60 wt % and in still another embodiment, it is present at 35 to 55 wt %, again based on the total weight of the PTF conductive composition.

B. Organic Media

The first organic medium is comprised of a thermoplastic urethane resin dissolved in a first organic solvent. The urethane resin must achieve good adhesion to the underlying substrate. It must be compatible with and not adversely affect the performance of the circuit after thermoforming.

In one embodiment the thermoplastic urethane resin is 10-50 wt % of the total weight of the first organic medium. In another embodiment the thermoplastic urethane resin is 15-45 wt % of the total weight of the first organic medium and in still another embodiment the thermoplastic urethane resin is 15-25 wt % of the total weight of the first organic medium. In one embodiment the thermoplastic urethane resin is a urethane homopolymer. In another embodiment the thermoplastic urethane resin is a polyester-based copolymer.

The second organic medium is comprised of a thermoplastic polyhydroxyether resin dissolved in a second organic solvent. It should be noted that the same solvent that is used in the first organic medium can be used in the second organic medium or a different solvent could be used. The solvent must be compatible with and not adversely affect the performance of the circuit after thermoforming. In one embodiment the thermoplastic polyhydroxyether resin is 10-50 wt % of the total weight of the second organic medium. In another embodiment the thermoplastic polyhydroxyether resin is 15-45 wt % of the total weight of the second organic medium and in still another embodiment the thermoplastic resin is 20-30 wt % of the total weight of the second organic medium.

The polymer resin is typically added to the organic solvent by mechanical mixing to form the medium. Solvents suitable for use in the organic media of the polymer thick film conductive composition are recognized by one of skill in the art and include acetates and terpenes such as carbitol acetate and alpha- or beta-terpineol or mixtures thereof with other solvents such as kerosene, dibutylphthalate, butyl carbitol, butyl carbitol acetate, hexylene glycol and high boiling alcohols and alcohol esters. In addition, volatile liquids for promoting rapid hardening after application on the substrate may be included. In many embodiments of the present invention, solvents such as glycol ethers, ketones, esters and other solvents of like boiling points (in the range of 180° C. to 250° C.), and mixtures thereof may be used. Various combinations of these and other solvents are formulated to obtain the viscosity and volatility requirements desired. The solvents used must solubilize the resin.

Third Organic Solvent

In one embodiment, the conductive composition further comprises a third organic solvent, diacetone alcohol. In an embodiment the diacetone alcohol is 1-20 wt % of the total weight of the PTF conductive composition.

In another embodiment the diacetone alcohol is 3-12 wt % of the total weight of the PTF conductive composition and in still another embodiment the diacetone alcohol is 4-6 wt % of the total weight of the PTF conductive composition.

Additional Powders

Various powders may be added to the PTF conductor composition to improve adhesion, modify the rheology and increase the low shear viscosity thereby improving the printability.

Application of the PTF Conductor Composition

The PTF conductor, also referred to as a "paste", is typically deposited on a substrate, such as polycarbonate, that is impermeable to gases and moisture. The substrate can also be a sheet of a composite material made up of a combination of plastic sheet with optional metallic or dielectric layers deposited thereupon. The transparent conductor may also be deposited on top of a thermoformable Ag conductor such as DuPont 5042 or 5043 (DuPont Co., Wilmington, Del.), or a thermoformable dielectric layer. Alternatively, a thermoformable Ag conductor may be formed on top of the transparent conductor.

The deposition of the PTF conductor composition is performed typically by screen printing, but other deposition techniques such as stencil printing, syringe dispensing or coating techniques can be utilized. In the case of screen-printing, the screen mesh size controls the thickness of the deposited thick film.

Generally, a thick film composition comprises a functional phase that imparts appropriate electrically functional properties to the composition. The functional phase comprises electrically functional powders dispersed in an organic medium that acts as a carrier for the functional phase. Generally, the composition is fired to burn out both the polymer and the solvent of the organic medium and to impart the electrically functional properties. However, in the case of a polymer thick film, the polymer portion of the organic medium remains as an integral part of the composition after drying and, therefore, is an integral part of the resultant conductor.

The PTF conductor composition is processed for a time and at a temperature necessary to remove all solvent. For example, the deposited thick film is dried by exposure to heat at 130° C. for typically 10-15 min.

Circuit Construction

The base substrate used is typically 10 mil thick polycarbonate. The conductor composition is printed and dried as per the conditions described above. Several layers can be printed and dried. Subsequent steps may include thermoforming (190° C., 750 psi) of the entire unit as is typical in the production of 3D capacitive switch circuits. In one embodiment an encapsulant layer is deposited over the dried PTF conductive composition, i.e., the transparent conductor, and then dried.

The encapsulant is comprised of the same organic mediums as contained in the PTF conductive composition, i.e., the same polymers in the same ratios as present in the PTF conductive composition. In another such embodiment, the encapsulant is comprised of the same organic mediums as contained in the PTF conductive composition, i.e., the same polymers but in different ratios than present in the PTF conductive composition.

In another embodiment, an encapsulant layer is deposited over the dried PTF conductive composition and then UV-cured. In this embodiment the encapsulant is comprised of one or more UV-curable polymers, e.g.; acrylate-based polymers. One PTF UV-curable composition suitable for forming an encapsulant layer is comprised of a high elongation urethane oligomer, an acrylate monomer, an acrylated amine and an inorganic powder.

It has been found that use of this encapsulant improves the yield (i.e. decreases the failure rate) of thermoformed circuits.

In the course of producing a 3-dimensional capacitive circuit, after the thermoforming step, the final step will often be a molding step in which the finished circuit is formed by injection molding using a resin such as polycarbonate. This process is referred to as in-molding and involves higher

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temperatures. Depending on the resin chosen, these temperatures can typically exceed 250° C. for 10-30 sec. Thus the choice of the resins used in the PTF composition is critical. The combination of the resins used in the instant PTF composition has been shown to survive the in-mold process and produce fully functional circuitry whereas most resins typically used in PTF compositions will not.

EXAMPLES, COMPARATIVE EXPERIMENTS

Example 1

The PTF transparent conductor composition was prepared in the following manner. 20 wt % of the first organic medium was used and was prepared by mixing 20.0 wt % Desmocoll 540 polyurethane (Bayer MaterialScience LLC, Pittsburgh, Pa.) with 80.0 wt % dibasic esters (obtained from DuPont Co., Wilmington, Del.) organic solvent. The molecular weight of the resin was approximately 20,000. This mixture was heated at 90° C. for 1-2 hours to dissolve all the resin. 50 wt % of an ITO powder with an average particle size of approximately 15 microns was added to the first organic medium. A printing additive (0.25 wt %) was also added. Finally, 30 wt % of a second organic medium was prepared by mixing and heating as described above 27.0% of polyhydroxyether resin PKHH (Phenoxy Associates, Rock Hill, S.C.) with 73.0% dibasic esters (obtained from DuPont Co., Wilmington, Del.). The second organic medium was then added to the first organic medium, the ITU powder and the printing additive mixture. The wt % of the first organic medium, the ITU powder, the printing additive and the second organic medium were based upon the total weight of the composition.

This composition was mixed for 30 minutes on a planetary mixer, and then subjected to several passes on a three roll-mill.

A circuit was then fabricated as follows. On a 10 mil thick polycarbonate substrate, a pattern of a series of interdigitated lines were printed using a 280 mesh stainless steel screen. The patterned lines were dried at 130° C. for 10 min in a forced air box oven. The part was inspected and minimal deformation of the underlying substrate was found. After thermoforming at 190° C., the conductive lines remained conductive and were well adhered to the substrate. Resistivity values of approximately 1600 ohms/sq/mil at 8 microns were obtained.

Example 2

The PTF transparent conductor composition was prepared in the following manner. 15.0 wt % of the first organic medium was used and was prepared by mixing 20.0 wt % Desmocoll 540 polyurethane (Bayer MaterialScience LLC, Pittsburgh, Pa.) with 80.0 wt % dibasic esters (obtained from DuPont Co., Wilmington, Del.) organic solvent. The molecular weight of the resin was approximately 20,000. This mixture was heated at 90° C. for 1-2 hours to dissolve all the resin. 35.0 wt % of an ATO powder (Zelec 3010-XC from Milliken Chemical, Spartanburg, S.C.) with an average particle size of approximately 0.5 microns was added to the first organic medium. Finally, 50.0 wt % of a second organic medium was prepared by mixing and heating as described above 27.0% of polyhydroxyether resin PKHH (Phenoxy Associates, Rock Hill, S.C.) with 73.0% dibasic esters (obtained from DuPont Co., Wilmington, Del.). The second organic medium was then added to the first organic medium and the ATO powder. The wt % of the first organic medium,

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the ATO powder, and the second organic medium were based upon the total weight of the composition.

This composition was mixed for 30 minutes on a planetary mixer, and then subjected to several passes on a three roll-mill.

A circuit was then fabricated as follows. On a 10 mil thick Polycarbonate substrate, a pattern of a series of interdigitated lines were printed using a 280 mesh stainless steel screen. The patterned lines were dried at 130° C. for 10 min in a forced air box oven. The part was inspected and minimal deformation of the underlying substrate was found. After thermoforming at 190° C., the conductive lines remained conductive and were well adhered to the substrate. Resistivity values of 1700 ohms/sq/mil were obtained at a dried thickness of approximately 7 microns.

Comparative Experiment 1

A circuit was produced exactly as described in Example 1. The only difference was that the second organic medium was not used. Inspection of the substrate showed that the composition showed minimal crazing and deformation of the underlying polycarbonate substrate. The conductive traces remained conductive after thermoforming as well although the overall quality of the traces was somewhat reduced.

Comparative Experiment 2

A circuit was produced exactly as described in Example 1. The only difference was that the conductive composition used contained a polyester resin in place of the urethane and polyhydroxyether resins. After thermoforming, the conductor lines were no longer conductive and did not adhere well to the substrate.

Example 3

A circuit was produced exactly as described in Example 1. The only difference was that 5 wt % of diacetone alcohol was added to the conductive composition of claim 1.

Inspection of the substrate showed that the composition showed no crazing or deformation of the underlying polycarbonate substrate. A definite improvement from Comparative Experiments 1 and 2 could be seen. There was also improvement over the minimal crazing or deformation of the underlying substrate found in Example 1.

The use of the urethane and polyhydroxyether resins clearly shows strikingly good results after thermoforming. Replacement with a different resin type i.e., polyester, renders the composition non-conductive after thermoforming. The additional improvement in resistance to crazing as a result of the presence of diacetone alcohol solvent is also apparent from the results shown above in Example 3.

What is claimed is:

1. A polymer thick film transparent conductive composition comprising:

- (a) 10-70 wt % of a conductive oxide powder selected from the group consisting of indium tin oxide powder, antimony tin oxide powder and mixtures thereof;
- (b) 10-50 wt % of a first organic medium comprising 10-50 wt % thermoplastic urethane resin dissolved in a first organic solvent, wherein the weight percent of the thermoplastic urethane resin is based on the total weight of the first organic medium; and

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- (c) 10-50 wt % of a second organic medium comprising 10-50 wt % thermoplastic polyhydroxyether resin dissolved in a second organic solvent; wherein the weight percent of said conductive oxide powder, said first organic medium and said second organic medium are based on the total weight of said polymer thick film conductive composition. 5
2. The polymer thick film transparent conductive composition of claim 1, further comprising
- (d) 1-20 wt % of a third organic solvent, wherein the third organic solvent is diacetone alcohol and wherein the weight percent is based on the total weight of said polymer thick film conductive composition. 10
3. The polymer thick film transparent conductive composition of claim 1, wherein said conductive oxide powder consists of particles in the form of flakes. 15
4. The polymer thick film transparent conductive composition of claim 1, wherein said thermoplastic urethane resin is a urethane homopolymer or a polyester-based copolymer.
5. A capacitive switch circuit comprising a transparent conductor formed from a polymer thick film conductive composition comprising: 20
- (a) 10-70 wt % of a conductive oxide powder selected from the group consisting of indium tin oxide powder, antimony tin oxide powder and mixtures thereof; 25
- (b) 10-50 wt % of a first organic medium comprising 10-50 wt % thermoplastic urethane resin dissolved in a first organic solvent, wherein the weight percent of the thermoplastic urethane resin is based on the total weight of the first organic medium; and 30
- (c) 10-50 wt % of a second organic medium comprising 10-50 wt % thermoplastic polyhydroxyether resin dissolved in a second organic solvent wherein the weight percent of the thermoplastic polyhydroxyether resin is based on the total weight of the second organic medium; 35
- wherein the weight percent of said conductive oxide powder, said first organic medium and said second organic medium are based on the total weight of said polymer thick film conductive composition and wherein said polymer thick film conductive composition is dried to form said transparent conductor and then said capacitive switch circuit is thermoformed. 40
6. The capacitive switch circuit of claim 5, said polymer thick film conductive composition further comprising; 45
- (d) 1-20 wt % of a third organic solvent, wherein the third organic solvent is diacetone alcohol and wherein the weight percent is based on the total weight of said polymer thick film conductive composition.
7. The capacitive switch circuit of claim 5, further comprising a thermoformable silver conductor, wherein said transparent conductor has been formed on said thermoformable silver conductor. 50
8. The capacitive switch circuit of claim 5, further comprising a thermoformable silver conductor, wherein, following the drying of said polymer thick film conductive composition to form said transparent conductor, said thermoformable silver conductor is formed on top of the transparent conductor before said capacitive switch circuit is thermoformed. 55
9. A capacitive switch circuit comprising a dried encapsulant layer and a transparent conductor formed from a dried polymer thick film conductive composition, said polymer thick film conductive composition comprising 60
- (a) 10-70 wt % of a conductive oxide powder selected from the group consisting of indium tin oxide powder, antimony tin oxide powder and mixtures thereof; 65

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- (b) 10-50 wt % of a first organic medium comprising 10-50 wt % thermoplastic urethane resin dissolved in a first organic solvent, wherein the weight percent of the thermoplastic urethane resin is based on the total weight of the first organic medium; and
- (c) 10-50 wt % of a second organic medium comprising 10-50 wt % thermoplastic polyhydroxyether resin dissolved in a second organic solvent wherein the weight percent of the thermoplastic polyhydroxyether resin is based on the total weight of the second organic medium; 5
- wherein the weight percent of said conductive oxide powder, said first organic medium and said second organic medium are based on the total weight of said polymer thick film conductive composition and wherein said polymer thick film conductive composition is dried before said encapsulant layer, comprising the same polymers present in said polymer thick film conductive composition in the same ratio or in different ratios, is deposited and dried.
10. A capacitive switch circuit comprising a UV-cured encapsulant layer and a transparent conductor formed from a dried polymer thick film conductive composition, said polymer thick film conductive composition comprising 10
- (a) 10-70 wt % of a conductive oxide powder selected from the group consisting of indium tin oxide powder, antimony tin oxide powder and mixtures thereof; 15
- (b) 10-50 wt % of a first organic medium comprising 10-50 wt % thermoplastic urethane resin dissolved in a first organic solvent, wherein the weight percent of the thermoplastic urethane resin is based on the total weight of the first organic medium; and 20
- (c) 10-50 wt % of a second organic medium comprising 10-50 wt % thermoplastic polyhydroxyether resin dissolved in a second organic solvent wherein the weight percent of the thermoplastic polyhydroxyether resin is based on the total weight of the second organic medium; 25
- wherein the weight percent of said conductive oxide powder, said first organic medium and said second organic medium are based on the total weight of said polymer thick film conductive composition and wherein said polymer thick film conductive composition is dried before said encapsulant layer, comprising one or more UV-curable polymers, is deposited and UV-cured. 30
11. The capacitive switch circuit of claim 9, said polymer thick film conductive composition further comprising 35
- (d) 1-20 wt % of a third organic solvent, wherein the third organic solvent is diacetone alcohol and wherein the weight percent is based on the total weight of said polymer thick film conductive composition. 40
12. The capacitive switch circuit of claim 9, wherein said capacitive switch circuit is thermoformed. 45
13. The capacitive switch circuit of claim 11, wherein said capacitive switch circuit is thermoformed. 50
14. The capacitive switch circuit of claim 9, further comprising a thermoformable silver conductor, wherein said transparent conductor has been formed on said thermoformable silver conductor and said encapsulant layer is deposited on said transparent conductor and dried. 55
15. The capacitive switch circuit of claim 9, further comprising a thermoformable silver conductor, wherein, following the drying of said polymer thick film conductive composition to form said transparent conductor, said thermoformable silver conductor is formed on top of the trans- 60

parent conductor before said encapsulant layer is deposited on said thermoformable silver conductor and dried.

16. The capacitive switch circuit of claim 14, wherein said capacitive switch circuit is thermoformed.

17. The capacitive switch circuit of claim 15, wherein said capacitive switch circuit is thermoformed.

18. An electrical circuit comprising a dried encapsulant layer and a transparent conductor formed from a dried polymer thick film conductive composition, said polymer thick film conductive composition comprising:

- (a) 10-70 wt % 10-70 wt % of a conductive oxide powder selected from the group consisting of indium tin oxide powder, antimony tin oxide powder and mixtures thereof;
- (b) 10-50 wt % first organic medium comprising 10-50 wt % thermoplastic urethane resin dissolved in a first organic solvent, wherein the weight percent of the thermoplastic urethane resin is based on the total weight of the first organic medium; and
- (c) 10-50 wt % second organic medium comprising 10-50 wt % thermoplastic polyhydroxyether resin dissolved in an organic solvent wherein the weight percent of the thermoplastic polyhydroxyether resin is based on the total weight of the second organic medium;

wherein the weight percent of said conductive oxide powder, said first organic medium and said second organic medium are based on the total weight of said polymer thick film conductive composition, wherein said polymer thick film conductive composition is dried to form said transparent conductor before said encapsulant layer, comprising the same polymers present in said polymer thick film conductive composition in the same ratio or in different ratios, is deposited and dried and wherein said electrical circuit is thermoformed.

19. An electrical circuit comprising a UV-cured encapsulant layer and a transparent conductor formed from a dried polymer thick film conductive composition, said polymer thick film conductive composition comprising:

- (a) 10-70 wt % 10-70 wt % of a conductive oxide powder selected from the group consisting of indium tin oxide powder, antimony tin oxide powder and mixtures thereof;
- (b) 10-50 wt % first organic medium comprising 10-50 wt % thermoplastic urethane resin dissolved in a first organic solvent, wherein the weight percent of the thermoplastic urethane resin is based on the total weight of the first organic medium; and
- (c) 10-50 wt % second organic medium comprising 10-50 wt % thermoplastic polyhydroxyether resin dissolved in an organic solvent wherein the weight percent of the thermoplastic polyhydroxyether resin is based on the total weight of the second organic medium;

wherein the weight percent of said conductive oxide powder, said first organic medium and said second organic medium are based on the total weight of said polymer thick film conductive composition, wherein said polymer thick film conductive composition is

dried to form said transparent conductor before said encapsulant layer, comprising one or more UV-curable polymers, is deposited and UV-cured and wherein said electrical circuit is thermoformed.

20. The electrical circuit of claim 18, said polymer thick film conductive composition further comprising

- (d) 1-20 wt % of a third organic solvent, wherein the third organic solvent is diacetone alcohol and wherein the weight percent is based on the total weight of said polymer thick film conductive composition.

21. The electrical circuit of claim 18, further comprising a thermoformable silver conductor, wherein said transparent conductor has been formed on said thermoformable silver conductor and said encapsulant layer is deposited on said transparent conductor and dried.

22. The electrical circuit of claim 18, further comprising a thermoformable silver conductor, wherein, following the drying of said polymer thick film conductive composition to form said transparent conductor, said thermoformable silver conductor is formed on top of the transparent conductor before said encapsulant layer is deposited on said thermoformable silver conductor and dried.

23. The capacitive switch circuit of claim 5, wherein said capacitive switch circuit is subsequently subjected to an injection molding process.

24. The capacitive switch circuit of claim 6, wherein said capacitive switch circuit is subsequently subjected to an injection molding process.

25. The capacitive switch circuit of claim 9, wherein said capacitive switch circuit is subsequently subjected to an injection molding process.

26. The capacitive switch circuit of claim 11, wherein said capacitive switch circuit is subsequently subjected to an injection molding process.

27. The electrical circuit of claim 18, wherein said electrical circuit is subsequently subjected to an injection molding process.

28. The electrical circuit of claim 20, wherein said electrical circuit is subsequently subjected to an injection molding process.

29. The capacitive switch circuit of claim 10, said polymer thick film conductive composition further comprising

- (d) 1-20 wt % of a third organic solvent, wherein the third organic solvent is diacetone alcohol and wherein the weight percent is based on the total weight of said polymer thick film conductive composition.

30. The capacitive switch circuit of claim 10, wherein said capacitive switch circuit is thermoformed.

31. The capacitive switch circuit of claim 29, wherein said capacitive switch circuit is thermoformed.

32. The electrical circuit of claim 19, said polymer thick film conductive composition further comprising (d) 1-20 wt % of a third organic solvent, wherein the third organic solvent is diacetone alcohol and wherein the weight percent is based on the total weight of said polymer thick film conductive composition.